



INFORMATION DISCLOSURE CITATION  
(Use several sheets if necessary)

Docket Number (Optional) <b>FIS920030300</b>	Application Number <b>10/707,009</b>
Applicant(s) <b>Furukawa et al.</b>	
Filing Date <b>11-13-03</b>	Group Art Unit

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

**Homma et al., "A Selective SiO<sub>2</sub> Film-Formation Technology Using Liquid-Phase Deposition for Fully Planarized Multilevel Interconnections", J. Electrochem. Soc., Vol. 140, No. 8, 1993, pp. 2410-2414.**

**Ching-Fa Yeh, et al., "Comprehensive Investigation on Fluorosilicate Glass Prepared by Temperature-Difference-Based Liquid-Phase Deposition", J. Electrochem. Soc., Vol. 147, No. 1, 2000, pp. 330-334.**

**Nagayama et al., "A New Process for Silica Coating", J. Electrochem. Soc., Vol. 135, No. 8, 1988, pp. 2013-2016.**

**Homma et al., "Optical Properties of Fluorinated Silicon Oxide and Organic Spin-on-Glass Films for Thin-Film Optical Waveguides", J. Electrochem. Soc., Vol. 147, No. 3, 2000, pp. 1141-1144.**

**Ching-Fa Yeh et al., "Novel Barrier Dielectric Liner Prepared by Liquid-Phase Deposition and NH<sub>3</sub> Plasma Annealing", Journal of Appl. Phys. Vol. 39, 2000, pp. 6672-6675.**

EXAMINER

DATE CONSIDERED

\*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

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Title of Invention	ALTERNATING PHASE MASK BUILT BY ADDITIVE FILM DEPOSITION
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Application Number :

Confirmation Number:

First Named Applicant: Toshiharu Furukawa

Attorney Docket Number: FIS920030300

Art Unit:

Examiner:

Search string: ( 4468420 or 4693916 or 4770901 or 4882183 or 5073408 or 5114760 or 5132140 or 5614270 or 5648128 or 5661051 or 6251753 or 6294832 ).pn

## US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
1	4468420	1984-08-28	Kawahara et al.				
2	4693916	1987-09-15	Nagayama et al.				
3	4770901	1988-09-13	Katoh et al.				
4	4882183	1989-11-21	Ino et al.				
5	5073408	1991-12-17	Goda et al.				
6	5114760	1992-05-19	Takemura et al.				
7	5132140	1992-07-21	Goda et al.				
8	5614270	1997-03-25	Yeh et al.				
9	5648128	1997-07-15	Yeh et al.				
10	5661051	1997-08-26	Yeh et al.				
11	6251753	2001-06-26	Yeh et al.				
12	6294832	2001-09-25	Yeh et al.				

## Signature

Examiner Name	Date
	6-29-05